



00839.000419.1

PATENT APPLICATION

IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
MAKOTO HIGASHIKAWA ET AL.) : Examiner: Maureen G. Arancibia
Application No.: 10/656,130) : Group Art Unit: 1763
Filed: September 8, 2003) :
For: PROCESS FOR FORMING A)
MICROCRYSTALLINE :
SILICON SERIES THIN)
FILM AND APPARATUS :
SUITABLE FOR PRACTICING)
SAID PROCESS : December 19, 2005

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

(a) Introductory Comments

In response to the Office Action dated September 20, 2005, kindly amend the subject application as follows: